


**REMARKS**

In response to the Office Action dated December 12, 2005, Applicants hereby elect Group II, claims 4-10, drawn to a laser irradiation method and method of manufacturing a semiconductor device.

Consideration and allowance of the instant application are now respectfully requested.

Respectfully submitted,



Jeffrey L. Costellia  
Registration No. 35,483

NIXON PEABODY LLP  
Suite 900, 401 9<sup>th</sup> Street, N.W.  
Washington, D.C. 20004-2128  
(202) 585-8000